

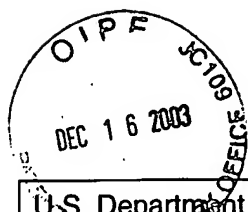
The patents and/or publications submitted herewith are set forth on the attached Form PTO-1449.

The Applicants do not feel that a fee is necessary at this time, but if the sum of \$180.00 is due under 37 CFR § 1.17(p) pursuant to § 1.97, the Commissioner is hereby authorized to charge this fee, and any other fee necessary to make this submission timely, to the Deposit Account No. 20-0782/APPM/6766/BTP.

Respectfully submitted,



Robb D. Edmonds
Registration No. 46,681
MOSER, PATTERSON & SHERIDAN, L.L.P.
3040 Post Oak Blvd., Suite 1500
Houston, TX 77056
Telephone: (713) 623-4844
Facsimile: (713) 623-4846
Attorney for Applicants



Sheet 1 of 7 sheets

U.S. Department of Commerce, Patent and Trademark Office (PTO Form 1449 modified)		Docket No. APPM/6766	Serial No. 10/712,690
INFORMATION DISCLOSURE STATEMENT BY APPLICANT		Applicant Chen, et al.	Confirmation No.
(Use several sheets if necessary)		Filing Date November 13, 2003	Group
Examiner Unknown			

U.S. Patent Documents

*Examiner Initial		Document Number	Issue Date	Applicant(s) Name	Class	Subclass	Filing Date If Appropriate
	A1	6,551,406	04/22/2003	KILPI	118	728	12/27/2000
	A2	6,511,539	01/28/2003	RAAIJMAKERS	117	102	09/08/1999
	A3	6,482,733	11/19/2002	RAAIJMAKERS, ET AL	438	633	04/26/2001
	A4	6,482,262	11/19/2002	ELERS, ET AL.	117	84	10/13/2000
	A5	6,481,945	11/19/2002	HASPER, ET AL.	414	217	06/04/1999
	A6	6,478,872	11/12/2002	CHAE, ET AL.	117	88	12/20/1999
	A7	6,475,910	11/05/2002	SNEH	438	685	09/22/2000
	A8	6,475,276	11/05/2002	ELERS, ET AL.	117	84	10/13/2000
	A9	6,468,924	10/22/2002	LEE, ET AL.	438	763	05/31/2001
	A10	6,451,695	09/17/2002	SNEH	438	685	12/22/2000
	A11	6,451,119	09/17/2002	SNEH, ET AL.	118	715	11/29/2000
	A12	6,447,607	09/10/2002	SOININEN, ET AL.	117	200	12/27/2000
	A13	6,416,577	07/09/2002	SUNTOLOA, ET AL.	117	88	12/09/1998
	A14	6,399,491	06/04/2002	JEON, ET AL.	438	680	04/06/2001
	A15	6,391,785	05/21/2002	SATTA, ET AL.	438	704	08/23/2000
	A16	6,379,748	04/30/2002	BHANDARI, ET AL.	427	255.394	01/17/2000
	A17	6,372,598	04/16/2002	KANG, ET AL.	438	399	06/16/1999
	A18	6,358,829	03/19/2002	YOON, ET AL.	438	597	09/16/1999
	A19	6,348,376	02/19/2002	LIM, ET AL.	438	253	01/19/2001
	A20	6,342,277	01/29/2002	SHERMAN	427	562	04/14/1999
	A21	6,306,216	10/23/2001	KIM, ET AL.	118	725	07/12/2000
	A22	6,305,314	10/23/2001	SNEH, ET AL.	118	723 R	12/17/1999
	A23	6,287,965	09/11/2001	KANG, ET AL.	438	648	02/23/2000
	A24	6,284,646	09/04/2001	LEEM	438	629	08/19/1998
	A25	6,270,572	08/07/2001	KIM, ET AL.	117	93	08/09/1999
	A26	6,231,672	05/15/2001	CHOI, ET AL.	118	715	05/18/1999
	A27	6,207,487	03/27/2001	KIM, ET AL.	438	238	10/12/1999

Examiner

Date Considered

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.



Sheet 2 of 7 sheets

U.S. Department of Commerce, Patent and Trademark Office (PTO Form 1449 modified)		Docket No. APPM/6766	Serial No. 10/712,690
INFORMATION DISCLOSURE STATEMENT BY APPLICANT		Applicant Chen, et al.	Confirmation No.
(Use several sheets if necessary)		Filing Date November 13, 2003	Group
Examiner Unknown			

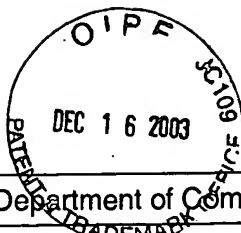
U.S. Patent Documents

*Examiner Initial		Document Number	Issue Date	Applicant(s) Name	Class	Subclass	Filing Date If Appropriate
	A1	6,203,613	03/20/2001	GATES, ET AL	117	104	10/19/1999
	A2	6,200,893	03/13/2001	SNEH	438	685	03/11/1999
	A3	6,197,683	03/06/2001	KANG, ET AL.	438	643	09/18/1998
	A4	6,183,563	02/06/2001	CHOI, ET AL.	118	715	05/18/1999
	A5	6,174,809	01/16/2001	KANG, ET AL.	438	682	12/15/1998
	A6	6,174,377	01/16/2001	DOERING, ET AL.	118	729	01/04/1999
	A7	6,144,060	11/07/2000	PARK, ET AL.	257	310	07/31/1998
	A8	6,139,700	10/31/2000	KANG, ET AL.	204	192.17	09/30/1998
	A9	6,124,158	09/26/2000	DAUTARTAS, ET AL.	438	216	06/08/1999
	A10	6,084,302	07/04/2000	SANDHU	257	751	12/26/1995
	A11	6,042,652	03/28/2000	HYUN, ET AL.	118	719	09/07/1999
	A12	6,015,917	01/18/2000	BHANDARI, ET AL.	556	12	01/23/1998
	A13	6,015,590	01/18/2000	SUNTOLA, ET AL.	427	255.23	11/28/1995
	A14	5,923,056	07/13/1999	LEE, ET AL.	257	192	03/12/1998
	A15	5,916,365	06/29/1999	SHERMAN	117	92	08/16/1996
	A16	5,879,459	03/09/1999	GADGLI, ET AL.	118	715	08/29/1997
	A17	5,855,680	01/05/1999	SOININEN, ET AL.	118	719	11/28/1995
	A18	5,835,677	11/10/1998	LI, ET AL.	392	401	10/03/1996
	A19	5,807,792	09/15/1998	ILG, ET AL.	438	758	12/18/1996
	A20	5,796,116	08/18/1998	NAKATA, ET AL.	257	66	08/18/1998
	A21	5,711,811	01/27/1998	SUNTOLA, ET AL.	118	711	11/28/1995
	A22	5,674,786	10/07/1997	TURNER, ET AL.	437	225	06/05/1995
	A23	5,503,875	04/02/1996	IMAI, ET AL.	427	255.3	03/17/1994
	A24	5,483,919	01/16/1996	YOKOYAMA, ET AL	117	89	08/17/1994
	A25	5,480,818	01/02/1996	MATSUMOTO, ET AL.	437	40	02/09/1993
	A26	5,443,647	08/22/1995	AUCOIN, ET AL.	118	723 ME	07/11/1994

Examiner

Date Considered

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.



U.S. Department of Commerce, Patent and Trademark Office (PTO Form 1449 modified)		Docket No. APPM/6766	Serial No. 10/712,690
INFORMATION DISCLOSURE STATEMENT BY APPLICANT		Applicant Chen, et al.	Confirmation No.
(Use several sheets if necessary)		Filing Date November 13, 2003	Group
Examiner Unknown			

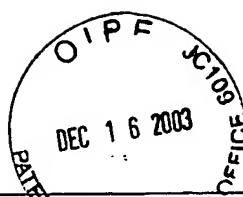
U.S. Patent Documents

*Examiner Initial		Document Number	Issue Date	Applicant(s) Name	Class	Subclass	Filing Date If Appropriate
	A1	5,441,703	08/15/1995	JURGENSEN	422	129	03/29/1994
	A2	5,374,570	12/20/1994	NASU, ET AL.	437	40	08/19/1993
	A3	5,294,286	03/15/1994	NISHIZAWA, ET AL.	156	610	01/12/1993
	A4	5,281,274	01/25/1994	YODER	118	697	02/04/1993
	A5	5,225,366	07/06/1993	YODER	437	108	06/22/1990
	A6	4,993,357	02/19/1991	SCHOLZ	118	715	12/21/1989
	A7	4,834,831	05/30/1989	NISHIZAWA, ET AL	156	611	09/04/1987
	A8	4,413,022	11/1/1983	SUNTOLA, ET AL.	427	255.2	06/21/1979
	A9	4,389,973	06/28/1983	SUNTOLA, ET AL.	118	725	12/11/1981
	A10	4,058,430	11/15/1977	SUNTOLA, ET AL.	156	611	11/25/1975
	A11	20030082296	05/01/2003	ELERS, ET AL.	427	96	09/12/2002
	A12	20030075925	04/24/2003	LINDFORS, ET AL.	285	367	06/28/2002
	A13	20030075273	04/24/2003	KILPELA, ET AL.	156	345.33	08/14/2002
	A14	20030072975	04/17/2003	SHERO, ET AL.	428	704	09/26/2002
	A15	20030049942	03/13/2003	HAUKKA, ET AL.	438	778	08/22/2002
	A16	20030042630	03/06/2003	BABCOKE, ET AL.	261	121.1	09/05/2001
	A17	20030031807	02/13/2003	ELERS, ET AL.	427	569	09/17/2002
	A18	20030013320	01/16/2003	KIM, ET AL.	438	778	05/31/2001
	A19	20030004723	01/02/2003	CHIHARA	704	260	01/29/2002
	A20	20020197402	12/26/2002	CHIANG, ET AL.	427	255.39	08/05/2002
	A21	20020187256	12/12/2002	ELERS, ET AL.	427	99	07/30/2002
	A22	20020182320	12/05/2002	LESKELA, ET AL.	427	250	03/15/2002
	A23	20020177282	11/28/2002	SONG	438	300	12/18/2001
	A24	20020164423	11/07/2002	CHIANG, ET AL.	427	255.28	05/03/2002
	A25	20020164421	11/07/2002	CHIANG, ET AL.	427	248.1	05/03/2002
	A26	20020162506	11/07/2002	SNEH, ET AL.	118	715	06/28/2002
	A27	20020155722	10/24/2002	SATTA, ET AL.	438	704	04/15/2002

Examiner

Date Considered

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.



U.S. Department of Commerce, Patent and Trademark Office		Docket No.	Serial No.
(PTO Form 1449 modified)		APPM/6766	10/712,690
INFORMATION DISCLOSURE STATEMENT BY APPLICANT		Applicant Chen, et al.	Confirmation No.
(Use several sheets if necessary)		Filing Date	Group
Examiner Unknown		November 13, 2003	

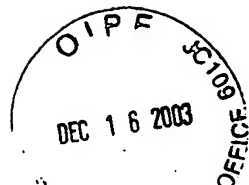
U.S. Patent Documents

*Examiner Initial		Document Number	Issue Date	Applicant(s) Name	Class	Subclass	Filing Date If Appropriate
	A1	20020146511	10/10/2002	CHIANG, ET AL.	427	248.1	10/24/2001
	A2	20020144657	10/10/2002	CHIANG, ET AL.	118	723 E	10/03/2001
	A3	20020144655	10/10/2002	CHIANG, ET AL.	118	715	10/24/2001
	A4	20020134307	09/26/2002	CHOI	118	715	11/30/2000
	A5	20020108570	08/15/2002	LINDFORS	118	715	04/16/2001
	A6	20020106536	08/08/2002	LEE, ET AL.	428	702	02/02/2001
	A7	20020104481	08/08/2002	CHIANG, ET AL.	118	723 I	03/19/2001
	A8	20020098627	07/25/2002	POMAREDE, ET AL.	438	149	08/31/2001
	A9	20020094689	07/18/2002	PARK	438	694	03/07/2002
	A10	20020092471	07/18/2002	KANG, ET AL.	118	715	01/16/2002
	A11	20020086106	07/04/2002	PARK, ET AL.	427	248.1	11/07/2001
	A12	20020076837	06/20/2002	HUJANEN, ET AL.	438	3	11/28/2001
	A13	20020076508	06/20/2002	CHIANG, ET AL.	427	569	12/19/2001
	A14	20020076507	06/20/2002	CHIANG, ET AL.	427	569	10/24/2001
	A15	20020076481	06/20/2002	CHIANG, ET AL.	427	8	10/24/2001
	A16	20020073924	06/20/2002	CHIANG, ET AL.	118	723 R	10/24/2001
	A17	20020068458	06/06/2002	CHIANG, ET AL.	438	694	11/26/2001
	A18	20020066411	06/06/2002	CHIANG, ET AL.	118	724	05/10/2001
	A19	20020052097	05/02/2002	PARK	438	507	05/03/2001
	A20	20020048635	04/25/2002	KIM, ET AL.	427	331	10/08/1999
	A21	20020041931	04/11/2002	SUNTOLA, ET AL.	427	255.28	05/14/2001
	A22	20020031618	03/14/2002	SHERMAN	427	569	10/09/2001
	A23	20020021544	02/21/2002	CHO, ET AL.	361	200	08/07/2001
	A24	20020020869	02/21/2002	PARK, ET AL.	257	306	12/20/2000
	A25	20020007790	01/24/2002	PARK	118	715	05/03/2001
	A26	20020000598	01/03/2002	KANG, ET AL.	257	301	07/26/2001
	A27	20020000196	01/03/2002	PARK	118	715	05/03/2001

Examiner

Date Considered

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.



Sheet 5 of 7 sheets

U.S. Department of Commerce, Patent and Trademark Office (PTO Form 1449 modified)		Docket No. APPM/6766	Serial No. 10/712,690
INFORMATION DISCLOSURE STATEMENT BY APPLICANT		Applicant Chen, et al.	Confirmation No.
(Use several sheets if necessary)		Filing Date November 13, 2003	Group
Examiner Unknown			

U.S. Patent Documents

*Examiner Initial		Document Number	Issue Date	Applicant(s) Name	Class	Subclass	Filing Date If Appropriate
	A1	20010054769	12/27/2001	RAAIJMAKERS, ET AL	257	758	04/26/2001
	A2	20010054730	12/27/2001	KIM, ET AL.	257	301	05/23/2001
	A3	20010054377	12/27/2001	LINDFORS, ET AL.	117	104	04/16/2001
	A4	20010042799	11/22/2001	KIM, ET AL.	239	553	02/02/2001
	A5	20010042523	11/22/2001	KESALA	122	6.6	05/14/2001
	A6	20010041250	11/15/2001	WERKHOVEN, ET AL.	428	212	03/06/2001
	A7	20010034123	10/25/2001	JEON, ET AL.	438	643	04/06/2001
	A8	20010028924	10/11/2001	SHERMAN	427	255.28	05/24/2001
	A9	20010025979	10/04/2001	KIM, ET AL.	257	315	12/04/2000
	A10	20010024387	09/27/2001	RAAIJMAKERS, ET AL	365	200	02/22/2001
	A11	20010014371	08/16/2001	KILPI	427	255.28	12/27/2000
	A12	20010013312	08/16/2001	SOININEN, ET AL.	117	86	12/27/2000
	A13	20010011526	08/09/2001	DOERING, ET AL.	118	729	01/16/2001
	A14	20010009695	07/26/2001	SAANILA, ET AL.	427	255.39	01/18/2001
	A15	20010009140	07/26/2001	BONDESTAM, ET AL.	118	725	01/25/2001
	A16	20010002280	05/31/2001	SNEH	427	255.28	12/22/2000
	A17	20010000866	05/10/2001	SNEH, ET AL.	118	723 R	11/29/2000

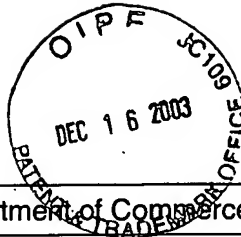
F Foreign Patent Documents

*Examiner Initial		Document Number	Date	Country	Class	Subclass	Translation	
							YES	NO
	B1	WO 02/45167	06/06/2002	WO	H01L	27/00	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B2	WO 02/43115	05/30/2002	WO	H01L		<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B3	WO 02/08488	01/31/2002	WO	C23C	16/44	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B4	WO 02/08485	01/31/2002	WO	C23C	16/00	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B5	WO 01/66832	09/13/2001	WO	C30B	25/14	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B6	WO 01/36702	05/25/2001	WO	C23C	16/00	<input type="checkbox"/>	<input checked="" type="checkbox"/>

Examiner

Date Considered

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.



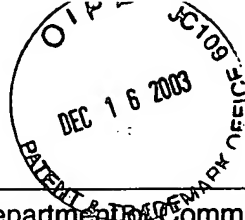
U.S. Department of Commerce, Patent and Trademark Office (PTO Form 1449 modified)		Docket No. APPM/6766	Serial No. 10/712,690
INFORMATION DISCLOSURE STATEMENT BY APPLICANT		Applicant Chen, et al.	Confirmation No.
(Use several sheets if necessary)		Filing Date November 13, 2003	Group
Examiner Unknown			

F Foreign Patent Documents

*Examiner Initial		Document Number	Date	Country	Class	Subclass	Translation	
							YES	NO
	B1	WO 01/29893	04/26/2001	WO	H01L	21/768	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B2	WO 01/29891	04/26/2001	WO	H01L	21/768	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B3	WO 01/29280	04/26/2001	WO	C23C	16/32	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B4	WO 01/27347	04/19/2001	WO	C23C	16/44	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B5	WO 01/27346	04/19/2001	WO	C23C	16/44	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B6	WO 01/17692	03/15/2001	WO	B05C	11/00	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B7	WO 01/15220	03/01/2001	WO	H01L	21/768	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B8	WO 00/79576	12/28/2000	WO	H01L	21/205	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B9	WO 00/54320	09/14/2000	WO	H01L	21/44	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B10	WO 00/16377	03/23/2000	WO	H01L		<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B11	WO 99/65064	12/16/1999	WO	H01L	21/00	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B12	WO 99/29924	06/17/1999	WO	C23C	16/04	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B13	WO 99/01595	01/14/1999	WO	C30B	25/14	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B14	WO 96/17107	06/06/1996	WO	C23C	16/44	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B15	58098917 (w/ English Abstract)	06/26/1983	JP	C23C	16/40	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B16	2001172767	06/26/2001	JP	C23C	16/40		<input checked="" type="checkbox"/>
	B17	2001-111000	04/20/2001	JP	H01L	21/316	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B18	2001020075 (Abstract Only)	11/15/2000	JP	C23C	16/44	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B19	2000319772 (Abstract Only)	03/28/2000	JP	C23C	16/00	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B20	6224138 (Abstract Only)	05/31/1994	JP	C30B	25/14	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B21	5270997 (Abstract Only)	10/19/1993	JP	C30B	29/68	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B22	5234899 (Abstract Only)	09/10/1993	JP	H01L	21/205	<input type="checkbox"/>	<input checked="" type="checkbox"/>

Examiner	Date Considered
----------	-----------------

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.



U.S. Department of Commerce, Patent and Trademark Office		Docket No.	Serial No.
(PTO Form 1449 modified)		APPM/6766	10/712,690
INFORMATION DISCLOSURE STATEMENT BY APPLICANT		Applicant Chen, et al.	Confirmation No.
(Use several sheets if necessary)		Filing Date	Group
Examiner Unknown		November 13, 2003	

Foreign Patent Documents

*Examiner Initial		Document Number	Date	Country	Class	Subclass	Translation	
							YES	NO
	B1	5206036 (Abstract Only)	08/13/1993	JP	H01L	21/205	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B2	5047666 (Abstract Only)	02/26/1993	JP	H01L	21/205	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B3	4291916 (Abstract Only)	09/23/1992	JP	C30B	25/10B	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B4	1 167 569	01/02/2002	EP	C23C	16/455	<input type="checkbox"/>	<input checked="" type="checkbox"/>
	B5	2 355 727	05/02/2001	GB	C23C	16/44	<input type="checkbox"/>	<input checked="" type="checkbox"/>

OTHER ART

*Examiner Initial		Including Author, Title, Date, Pertinent Pages, Etc.
	C1	Kukli, <i>et al.</i> , "Tailoring the Dielectric Properties of HfO ₂ -Ta ₂ O ₅ Nanolaminates," Applied Physics Letters, Vol. 68, No. 26, June 24, 1996; p. 3737-9
	C2	Kukli, <i>et al.</i> "Atomic Layer Epitaxy Growth of Tantalum Oxide Thin Films from Ta(OC ₂ H ₅) ₅ and H ₂ O," Journal of the Electrochemical Society, Vol. 142, No. 5, May 1995; p. 1670-5
	C3	Kukli, <i>et al.</i> , "In situ Study of Atomic Layer Epitaxy Growth of Tantalum Oxide Thin Films From Ta(OC ₂ H ₅) ₅ and H ₂ O," Applied Surface Science, Vol. 112, March 1997, p. 236-42
	C4	Kukli, <i>et al.</i> , "Properties of Ta ₂ O ₅ -Based Dielectric Nanolaminates Deposited by Atomic Layer Epitaxy," Journal of the Electrochemical Society, Vol. 144, No. 1, Jan. 1997; p. 300-6
	C5	Kukli, <i>et al.</i> , "Properties of {Nb _{1-x} Ta _x } ₂ O ₅ Solid Solutions and {Nb _{1-x} Ta _x } ₂ O ₅ -ZrO ₂ Nanolaminates Grown by Atomic Layer Epitaxy," 1997; p. 785-93
	C6	Ritala, M., <i>et al.</i> , "Chemical Vapor Deposition," January 1999, p. 6-9
	C7	Rossnagel, <i>et al.</i> "Plasma-enhanced Atomic Layer Deposition of Ta and Ti for Interconnect Diffusion Barriers," J. Vac. Sci. Technol. B., Vol. 18, No. 4 (July 2000); p2016-20
	C8	Niinisto, <i>et al.</i> "Synthesis of Oxide Thin Films and Overlayers by Atomic Layer Epitaxy for Advanced Applications," Materials Science and Engineering B41 (1996) 23-29
	C9	Eisenbraun, <i>et al.</i> "Atomic Layer Deposition (ALD) of Tantalum-based materials for zero thickness copper barrier applications," Proceedings of the IEEE 2001 International Interconnect Technology Conference (Cat. No. 01EX461) 2001
	C10	Clark-Phelps, <i>et al.</i> "Engineered Tantalum Aluminate and Hafnium Aluminate ALD Films for Ultrathin Dielectric Films with Improved Electrical and Thermal Properties," Mat. Res. Soc. Symp. Proc. Vol. 670 (2001)

Examiner	Date Considered
----------	-----------------

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.